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(REV. 8-83)US Dept. of Commerce  
PATENT & TRADEMARK OFFICEATTY DOCKET NO.  
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09/950,073

## INFORMATION DISCLOSURE STATEMENT

(Use several sheets if necessary)

APPLICANT(S)  
Patrick PERDU et al.FILING DATE  
September 21, 2001

GROUP 2854

## U.S. PATENT DOCUMENTS

| EXAMINER<br>INITIAL | DOCUMENT NUMBER | DATE  | NAME           | CLASS | SUB<br>CLASS |
|---------------------|-----------------|-------|----------------|-------|--------------|
| ne                  | 5,559,606       | 09/96 | WEBSTER et al. | 358   | 296          |
|                     |                 |       |                |       |              |
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## FOREIGN PATENT DOCUMENTS

| DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUB<br>CLASS |
|-----------------|------|---------|-------|--------------|
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## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

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EXAMINER

MINDY CHALL

DATE CONSIDERED 09-12-05

Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.